

MRS Meetings Scheduled for Tokyo in 1988

MRS Vice President R.P.H. (Bob) Chang recently visited Taiwan and Japan to further plan for three meetings to be held in Tokyo in mid-1988. During the past several years MRS has observed a steady increase in the number of members from Asian countries. Many Asian scientists indicated that they very much like the interdisciplinary approach to the MRS meeting structure. Almost exactly two years ago Chang was sent by MRS to Japan and China to further inform materials scientists there about the Materials Research Society and to encourage them to try the MRS-style meeting format. As a result of several discussions it was agreed that MRS should cosponsor an international meeting in Japan for the benefit of Asian materials researchers. Since then the planning of such a meeting has been under way, with most of the work done by materials research colleagues in Japan.

Chang reported that his recent trip to Taiwan was to encourage materials scientists there to actively participate in the 1988 International MRS Meetings in Japan. He also suggested to the president of the Taiwan Materials Society the possibility of joint sponsorship of MRS-style symposia. His visit to Japan was for the purpose of attending a program committee meeting.

"The government of Taiwan has put a lot of emphasis on materials research and development during the past several years," Chang remarked. "Since my last visit to Taiwan (about six years ago) they have established a very impressive materials research laboratory (with Dr. O.C.C. Lin as director) in the Hsinchu research park. Plans are also under way for the construction of synchrotron facilities."

Chang is very enthusiastic about the programs for the 1988 Tokyo Meetings. "Our colleagues in Japan have already done a tremendous amount of preparation work," he said. He described the events planned this far. During the last week of May there will be a major exhibition on Advanced Materials in Tokyo, in which MRS will have an exhibit. Expected attendance at the exhibition is about 300,000.

The International Advanced Materials Meeting with 15 topical symposia will be held during the first week of June. This meeting will be conducted in a similar fashion as the MRS Spring and Fall Meetings in the United States. Expected attendance for this meeting is about 1,000.

During June 12-17, 1988, two other meetings will take place in Tokyo. They are the JSAP-MRS International Conference on Electronic Materials and the International Conference on Ion Beam Modification of Materials, also cosponsored by MRS. An-

nouncements to these meetings will be sent to the membership.

Chang anticipates the meetings to provide valuable insight into materials research. "As you know," he said, "the Japanese are extremely busy working on the high T_c oxide materials as are the people in the United States. I expect to see some important technological breakthrough from them in this area. The other important piece of information I learned from my colleagues in Japan was that a new research consortium is being formed between industry and the Japanese government in the area of advanced materials processing and machining."

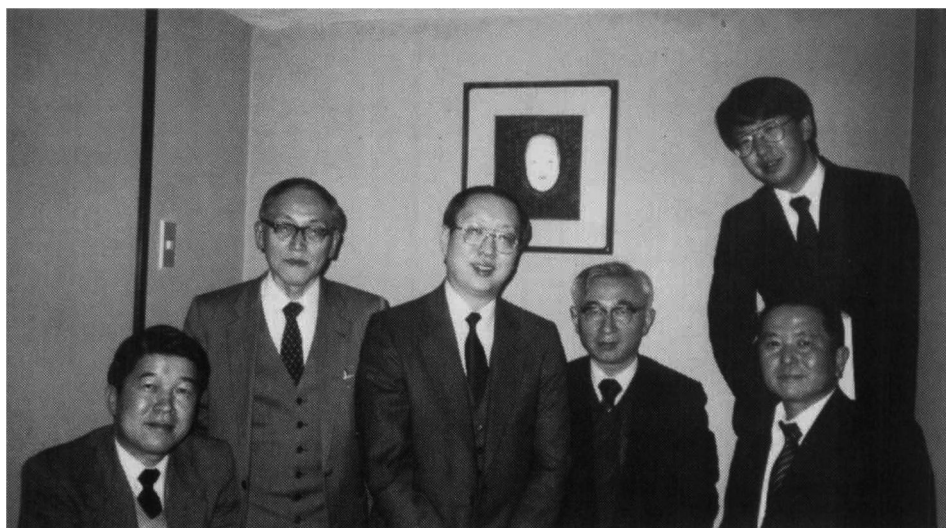
Further details on the meetings will appear in future issues of the BULLETIN. (See *Upcoming Conferences in this issue for preliminary call for papers information.*)

MRS Council Discusses Progress, Plans for 1987 at Spring Meeting

The Materials Research Society Council met April 24-25, 1987 during the 1987 MRS Spring Meeting in Anaheim, CA. The following is a summary of some of the highlights of that meeting.

Treasurer Sue Kelso reported that MRS finished 1986 slightly above budget. The Designated Fund authorized by Council at its December 1986 meeting for long-term purposes has been established. The Von Hippel Award, which the Society self-endows, will be financed as part of this Designated Fund.

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Organizers and sponsors for the upcoming Tokyo meetings (left to right): K. Otsuka, M. Doyama, R.P.H. Chang (MRS coordinator), S. Sōmiya, T. Ichikawa, and Y. Kato (behind).



JSAP-MRS International Conference on Electronic Materials (left to right): cochair T. Kamiya, organizer T. Sugano, and cochair R.P.H. Chang.